

5-08-03

1756

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:

SABNIS, RAM W. et al.

Serial No.: 09/745,350

Filed: December 21, 2000

ORGANIC POLYMERIC ANTIREFLECTIVE  
COATINGS DEPOSITED BY CHEMICAL  
VAPOR DEPOSITION

Docket No.: 27710-A

Group Art Unit No.: 1756

Examiner: BARRECA, NICOLE M.

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TRANSMITTAL

Transmitted herewith are: Transmittal; Petition for Extension of Time (1 page) with check (\$465.00); Amendment (16 pages); Exhibit A "Synthesis and Chemistry of Several Fluorinated *p*-xylenes Designed as Precursors for  $\alpha, \alpha, \alpha', \alpha'$  - Tetrafluoro-*p*-Xylenes" (8 pages); Exhibit B "Parylene Conformal Coatings and Properties" (6 pages); and return postcard.

EV 343763255 US

Express Mail No.

Respectfully submitted,

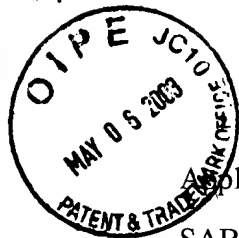
HOVEY WILLIAMS LLP

Dated: May 6, 2003

by

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ATTORNEYS FOR APPLICANT



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Assistant Commissioner of Patents  
Washington, D.C. 20231

Sir:

AMENDMENT

In response to the Office Action dated November 6, 2002, amendment and reconsideration of the above Application is requested.

Claims:

Please amend the claims as follows:

1. (Amended) A method of forming a precursor for use in manufacturing integrated circuits comprising the steps of:

providing a quantity of an antireflective compound and a substrate having a surface onto which said compound is to be applied, said antireflective compound having the formula

C,